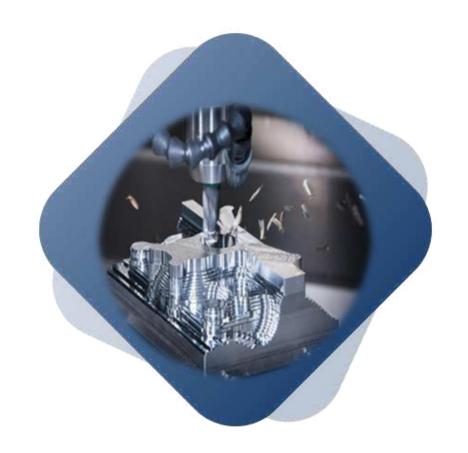


Heeger Materials Inc.

About Our Company

- Heeger Materials is a leading supplier and manufacturer of highquality products tailored for global customers.
- Our mission is to deliver superior products that empower our customers to achieve their goals efficiently.



Our Core Materials

Committed to excellence, **Heeger Materials** leverages cutting-edge technology and rigorous quality control to ensure that our offerings meet the highest industry standards.



Spherical Powder

High-quality spherical metal and alloy powders suitable for 3D printing and other applications.



Sputtering Targets

A wide array of sputtering targets for thin-film deposition, available in various materials to meet specific industry needs.



Refractory Metals

Durable metals that retain their strength at high temperatures, including Tantalum, Tungsten, Molybdenun, and others.



Rare Earth Mateirals

Essential elements for modern technologies, including rare earth metal, oxide, compounds, and more.



High Purity Mateirals

Materials with high purity levels for specialized applications, ensuring optimal performance and quality.



Technical Ceramics

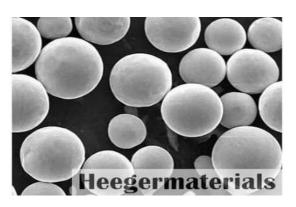
Advanced ceramic materials designed for engineering applications, offering high strength and resistance.

Spherical Powder

Main Products

- > Cobalt Alloy Powders: CoCrMo, CoCrMoW
- > Titanium Alloy Powders: Ti-6Al-4V, TiMoZr
- > Aluminum Alloy Powders: AlSi10Mg, AlMgSc
- > Hing-entropy Alloy (HEA) Powders: WMoTaNbV, FeCoNiCrMo
- > Soft Magnetic Alloy Powders: FeSiAl, FeSiCr
- > Brazing Alloy Powders: SnAgCu, CuSnTi

- ➤ Additive Manufacturing
- Metal Injection Molding (MIM)
- > Coating and Spray
- ➤ Hot Isostatic Pressing (HIP)





Sputtering Targets

Main Products

- > Pure Metal Sputtering Targets: Al, Sb, Cd, Cr, Eu, Gd
- > Alloy Sputtering Targets: Al/Ti, Cr/V, Ce/Gd, Ti/Al/V
- > Ceramic Sputtering Targets: BN, SiC, WC, AIN
- > Composite Sputtering Targets: ZnO/Al2O3, ZrO2/Y2O3

- Physical Vapor Deposition (PVD) Sputtering Targets:
 Vacuum Evaporation, Sputtering, and other techniques.
- Chemical Vapor Deposition (CVD) Sputtering Targets:
 Chemical Vapor Deposition processes.





SiC Sputtering Target

Refractory Metals

Main Products

➤ HM offers a range of high-performance refractory metals, including tungsten (W), molybdenum (Mo), tantalum (Ta), niobium (Nb), zirconium (Zr), hafnium (Hf), rhenium (Re), and their alloys, known for their high melting points, strength, and resistance to thermal and chemical degradation.

- ➤ **Grain Refinement**: Essential for casting hightemperature alloy steels and nonferrous metals.
- ➤ **Medical Devices**: Tantalum and rhenium are used in artificial joints and implantable devices.
- ➤ Industrial Applications: Tungsten and molybdenum are used in high-temperature furnaces and electrodes.
- ➤ Aerospace Industry: Commonly used for aircraft engine parts that withstand high temperatures and pressures.



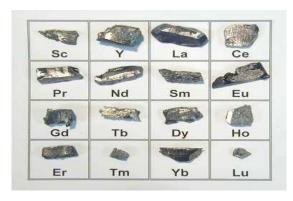


Molybdenum Customized Part

Rare Earth Materials

Main Products

➤ HM specializes in providing La, Ce, Pr, Nd, Pm, Sm, Eu, Gd, Tb, Dy, Ho, Er, Tm, Yb, Lu, Sc, and Y, along with their oxides and alloys. These materials are crucial for various advanced applications due to their unique magnetic, luminescent, and catalytic properties.



- Metallurgy and alloys
- **≻** Catalysts
- > Ceramics, pigments, and glazes
- > Permanent magnets



Cerium (Ce) Rods

High Purity Materials

Main Products

HM specializes in manufacturing high purity and ultra-high purity materials ranging from 99.99% (4N) to 99.999999% (8N). Available forms include ingot, granule, lump, crystal, rod, and powder.

- ➤ Pure metal: Gallium (Ga), Germanium (Ge), Indium (In), Antimony (Sb)
- > Oxides: CdO, SnO2, TeO2, Bi2O3, In2O3, Bi2Te3
- > Compounds: CdTe, CdS, SnTe, SnS, GeS, CulnS2

- > Thin film deposition
- Crystal growth of semiconductors
- > Synthesis of nanomaterials
- Advanced microelectronics, solar cells, fuel cells, and optical materials





Bismuth Telluride (Bi2Te3)

Technical Ceramics

HM's technical ceramics are designed for high-performance applications, providing exceptional strength, thermal stability, and chemical resistance. Available forms include components, substrates, and custom shapes.

Main Products

- ➤ Alumina (aluminum oxide, Al2O3)
- ➤ Boron Nitride (BN) and Pyrolytic Boron Nitride (PBN)
- Zirconia (zirconium oxide, ZrO2)
- Silicon Nitride (Si3N4) and SiAION (alumina substituted into silicon nitride)
- ➤ Aluminum Nitride (AIN)
- ➤ Tungsten Carbide (WC)
- ➤ Silicon Carbide (SiC)
- ➤ Boron Carbide (BC) and diamond

Applications

> Aerospace, Automotive, Electronics





ZSBN Tube

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